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APPLICATION NO.	FILING DATE		FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/632,631	0/632,631 07/31/2003		Edward Hin Pong Lee		HIT1P016/HSJ9-2003-0096US 6355		
50535	7590	07/19/2005		EXAMINER			
ZILKA-KOTAB, PC P.O. BOX 721120				CULBERT, ROBERTS P			
SAN JOSE, CA 95172-1120					ART UNIT	PAPER NUMBER	
ŕ					1763		

DATE MAILED: 07/19/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)						
	10/632,631	LEE ET AL.						
Office Action Summary	Examiner	Art Unit						
	Roberts Culbert	1763						
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet \	with the correspondence ad	dress					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a ly within the statutory minimum of th will apply and will expire SIX (6) MO e, cause the application to become	a reply be timely filed hirty (30) days will be considered timel DNTHS from the mailing date of this c ABANDONED (35 U.S.C. § 133).						
Status								
1) Responsive to communication(s) filed on 18 h	<i>lay 2005</i> .							
2a) ☐ This action is FINAL . 2b) ☐ This	s action is non-final.							
,	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice under I	Ex parte Quayle, 1935 C.	D. 11, 453 O.G. 213.						
Disposition of Claims								
4) Claim(s) <u>1-29</u> is/are pending in the application	· · · · · · · · · · · · · · · · · · ·							
4a) Of the above claim(s) <u>10-14 and 19-29</u> is/a	are withdrawn from consid	deration.						
5) Claim(s) 15-18 is/are allowed.								
6) Claim(s) <u>1-9</u> is/are rejected.								
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/o	or election requirement							
	or election requirement.							
Application Papers								
9) The specification is objected to by the Examine		atad ta butha Fugatan						
10)⊠ The drawing(s) filed on <u>31 July 2003</u> is/are: a)								
Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct	- · ·	, ,	ED 1 121(d)					
11) The oath or declaration is objected to by the Ex	•	•	• •					
Priority under 35 U.S.C. § 119			·					
<u> </u>								
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 		§ 119(a)-(d) or (f).						
2. Certified copies of the priority document		Application No						
3. Copies of the certified copies of the prio	rity documents have bee	n received in this National	Stage					
application from the International Burea	u (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list	of the certified copies no	t received.						
AMashanan4/a)								
Attachment(s) 1) Notice of References Cited (PTO-892)	4) Interview	Summary (PTO-413)						
2) D Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No	(s)/Mail Date						
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 	5)	Informal Patent Application (PTC)-152)					
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DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of Species B (illustrated in Fig 8-11) in the reply filed on 5/18/05 is acknowledged.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-4 and 9 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent 6,119,331 to Chang et al.

Regarding Claim 1, Chang et al. teach a method for fabricating a magnetic head comprising forming a first pole (200); forming a cap (204) above the first pole (Col. 7, Lines 25-56) empty side regions being positioned laterally on opposite sides of the cap (Figure 10); forming a dielectric gap layer (205) above the cap (Col. 7, Lines 62-65); forming a second pole layer above the gap layer (Col. 8, Lines1-3); and milling the structure for creating a shoulder of the first pole tapering upwardly towards the cap (Col. 8, Lines 50-55).

Regarding Claim 2, Chang et al. teach filling the side regions with a material selected from a group consisting of a dielectric, a material susceptible to removal by reactive ion etching and a material susceptible to milling.

Regarding Claim 3, Chang et al teach in sequence, prior to milling, removing the exposed portions of the gap layer, and removing the material used to refill the side regions. (Note that the material may be the same material as the exposed portions of the gap layer since the "in sequence" limitation of the claim may simply refer to performing the steps after milling, as it occurs in the Chang et al. reference.

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Regarding Claim 4, Chang et al. teach that side edges of the second pole, gap layer and cap are vertically aligned. (See Figure 19, for example)

Regarding Claim 9, the structure is ion milled. (Col. 8, Lines 42-50)

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 5-7, are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent 6,119,331 to Chang et al. in view of U.S. Patent application Publication 2001/0055879 to Sasaki.

Regarding Claims 5-7, as applied above to claims 1-4 and 9, Chang et al. teach the method of the invention substantially as claimed, but do not explicitly teach the various materials of the gap layer.

However, materials such as alumina, silicon dioxide, and other suitable non-magnetic materials are old and well known in the art of forming the gap layer of a magnetic head. (See, for example Paragraph 73 of Sasaki.)

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It would have been obvious to one of ordinary skill in the art at the time of invention to use the artrecognized gap materials in order to provide an induction for the magnetic head in the well-known manner.

Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent 6,119,331 to Chang et al.

Regarding Claim 8, as applied above to claims 1-4 and 9, Chang et al. teach the method of the invention substantially as claimed, but do not explicitly state that the second pole is formed on a seed layer, however Chang et al. points out that a seed layer is old and well known for the purpose of frame plating a second pole layer on a gap layer in the fabrication of a magnetic head. (Col. 2, Lines 1-5) It would have been obvious to pe of ordinary skill in the art at the time of invention to use a seed layer in the well-known manner in order to provide adhesion off a plated pole layer to a gap layer in the fabrication of a magnetic head.

Allowable Subject Matter

Claims 15-18 are allowed.

The following is an examiner's statement of reasons for allowance:

The prior art of record fails to teach or render obvious a method of fabricating a magnetic head comprising; forming a first pole; forming a cap above the first pole; removing opposite side regions of the cap; refilling the side regions with a material selected from a group consisting of a dielectric, a material susceptible to removal by reactive ion etching, and a material susceptible to removal by milling; forming a gap layer above the cap; forming a second pole above the gap layer; removing exposed portions of the gap layer; removing the material used to refill the side regions, thereby exposing peripheral regions of the cap; and milling the cap and first pole for creating a shoulder of the first pole tapered upwardly towards the cap; wherein side edges of the second pole, gap layer, and cap are substantially vertically aligned after the milling.

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Any comments considered necessary by applicant must be submitted no later than the payment

of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such

submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should

be directed to Roberts Culbert whose telephone number is (571) 272-1433. The examiner can normally

be reached on Monday-Friday (8:30-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor,

Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization

where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application

Information Retrieval (PAIR) system. Status information for published applications may be obtained from

either Private PAIR or Public PAIR. Status information for unpublished applications is available through

Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC)

at 866-217-9197 (toll-free).

K. Collet

R. Culbert

PARVIZ HASSENZADEH
SUPERVISORY PATENT EXAMINER

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